

# Accelerator Vacuum Technology Challenges for Next-Generation Synchrotron-Light Sources

P. He (IHEP)

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- 2. Future trends in DLSR (Diffraction Limited Storage Rings)
- 3. Associated Vacuum Issues and Special Hardware Development
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# Introduction

Goals and the target performance of LS (Light Source) storage rings:

Constant delivery of a high quality, intense and stable photon beam to a large number of beamlines

High quality and intense photon beams: Often characterized in terms of

Brilliance = 
$$\frac{Photons}{Second \cdot mrad^2 \cdot mm^2 \cdot 0.1\%BW} \propto \frac{I}{\varepsilon_x \varepsilon_y}$$

*I* : Beam current,  $\varepsilon_u$  : Transverse emittance

Presently a big global wave for 3GLS  $\rightarrow$  DLSR (Diffraction Limited Storage Rings or 4GLS)

Lowering of transverse beam emittance

Optimal ring structure from DBA, TBA lattice -> MBA lattice

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# **Ring-Based LS Future Trends**

A global wave today to construct (or *reconstruct*) ring-based LSs having the horizontal emittance ε<sub>H</sub> by tens of factors below the "nm·rad" range

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Basic principle used:







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### MBA (Multiple Bend Achromat) instead of DBA, TBA



Comparison between ESRF and ESRF-EBS

Especially for machine "upgrades", the resultant ring configuration tends to be extremely dense APS  $\rightarrow$  APS\_U, Spring\_8  $\rightarrow$  Spring\_8 II, ESRF  $\rightarrow$  EBS

Low emittance  $\rightarrow$  Strong focusing  $\rightarrow$  Smaller bore radii  $\rightarrow$  Narrower VC aperture  $\rightarrow$  Higher impedance (Resistive-Wall & Broadband)  $\rightarrow$  Lower vacuum conductivity  $\rightarrow$  Special vacuum technology (NEG, ...)



### **Challenges on vacuum systems for Low Emittance/DLSRs**

Main Purpose of DLSRs\_Vacuum System Design: Have low dynamic pressure which gives good beam lifetime, and to handle the power deposited by SR.

- High gradient quadruple → Small magnet bore aperture
  Vacuum Chamber designs compatible with magnet poles, photon extraction and beam stay clear conditions(space limitation)
- Handle the power deposited by SR →
  Integration of pumping ports, photon absorbers, collimators and crotches(high SR power)
- Small magnet bore aperture → Low profile vacuum chamber(Lumped pumping would not be as efficient in reducing the pressure)
   Detailed evaluation of vacuum profiles along the ring(conductance limitation)
- → NEG coating must be a very helpful method for DLSRs to provide distributed pumping
- Some specific hardware development in future DLSRs "Zero-impedance" flange, RF\_shield Bellow, BPM etc...
- In-situ baking materials development thin Polyimide foil heater + AI coating polyimide foil

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# **New LS's Parameters**

### Table 1: New Ring-Based LS's Parameters

Facility	<u>C(</u> m).	E(GeV)/I(A)	Mag. Bore(mm)	Chamber Material	Baking
		Ex(pm.rad)			Method
MAX-IV	528	3/0.5	25	OFS Cu	Ex-situ
(Sweden)	(20cell-7BA)	330		(100% NEG Coating)	
SIRIUS (Brazil)	518.4	3/0.5	28	OFS Cu	In-situ
	(20cell-5BA)	250		(100% NEG Coating)	
EBS (France)	844	6/0.2	26	SST/Al	In-situ
	(32cell-7BA)	135		(Partial NEG Coating)	
SPring-8_U	1436	6/0.1	26	SST	Ex-situ
(Japan)	(48cell-5BA	140		(No NEG Coating)	
APS_U (USA)	1100	6/0.2	26	OFS Cu/Al	Ex-situ
	(40cell-7BA)	60		(Partial NEG Coating)	

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### Vacuum Chamber Design(1)

The clearance between the chambers and the magnets poles is 0.5~1.0 mm; the chambers are produced with tight mechanical tolerances to avoid any interference with the magnet poles and coils (for example, all tolerances of the chambers should be less than 0.3 mm).

#### **Ø22 mm**





Aperture limiting sextupole

#### MAX-IV Dipole Chamber



- Wire erosion.
- TIG welding.
- E-beam welding
- Bending.
- Brazing.

#### MAX-IV Sextupole Chamber with Key-Hole

Technologies applied:

- Milling.
- Etching.
- Turning.
- NEG-coating
- Etc..

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### Vacuum Chamber Design(2)

EBS chambers(low profile) are going to be installed in the central DQ (Dipole Quadrupole) magnets



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## Handle higher SR Power(1)

Integration of pumping port and photon absorber Compact geometry with adequate cooling and minimized radiation scattering

In-line absorber was used for shadow following BPM

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SIRIUS







bsorber to shadow

APS-U

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# Handle higher SR Power(2)



- 12 lumped removable photon absorbers (on flanges) per cell
- These absorbers will be machined from a block CuCrZr, including the CF knife edge Single piece construction without brazing or welding.

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# Handle higher SR Power(3)

#### Material Selection "Glidcop AL-15 Vs Copper Chromium Zirconium (C18150)"

#### **Material Properties**

Thermal Conductivity (RT):
 Glidcop Al25, Al15: 344 - 365 W/(m.K)
 Cu-Cr-Zr: 314 - 335 W/(m.K)

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- Elastic Modulus:
  Glidcop Al15, Al25: 130 GPa Cu-Cr-Zr: 123 GPa
- O.2 % Yield Strength, (RT, Cold Worked): Glidcop Al15, Al25: 470 - 580 MPa Cu-Cr-Zr: 350 - 550 Mpa
- Coefficient of Thermal Expansion: Glidcop Al15, Al25: 16.6 μm/K Cu-Cr-Zr: 17.0 μm/K

- Cu-Cr-Zr (C18150) is 1/4<sup>th</sup> the price of Glidcop AL-15.
- Cu-Cr-Zr is readily available in different forms and sizes from many suppliers.
- Cu-Cr-Zr loses its strength rapidly if exposed to sustained temperatures > 500°C
- Glidcop is the choice if brazing is required.

Ref: Li M. and Zinkle S. J. (2012) Physical and Mechanical Properties of Copper and Copper alloys, Comprehensive Nuclear Materials, Vol. 4, pp 667-690

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High brightness

At affordable cost



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## **Distribution Pumping\_NEG coating(1)**

Magnetic poles close to the beam

Smaller aperture beam pipes

e-bean

MAX-IV

Distributed pumping

20 chambers of each

model coated @CERN

NEG coating, which turned out to be very effective in pumping the residual gases without pumping ports, is more and more used in ring-based LSs.

MAX-IV and SIRRUS NEG coating for whole ring EBS and APS-U NEG coating for partial ring NEG coating issues

- Coating very small aperture even <10mm chambers
- Surface roughness
- Coating photon extraction key hole(~6mm gap) is challenging
- Fabrication methods compatibility with coating processes
- Coating development in industry. Very limited vendor capability-a possible risk
- NEG impedance might become a problem for very short bunches



### **NEG Coating Facility around the world**



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### **NEG Coating Procedure**

#### LNLS/SIRIUS



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### **Coating Parameters Optimizations**

WD = 4.2 mm

ag = 50.00 K 3

21 Jun 2012



composition and microstructure affects activation energy and pumping performance

#### Table 1

#### Daresbury/UK

Sticking probabilities for different gases and CO sorption capacity for the columnar and dense samples activated at different temperatures  $T_{a}$ .

Ta	Dense					Columnar			
	Sticking probability		CO sorption capacity		Sticking probability			CO sorption capacity [ML]	
	H <sub>2</sub>	СО	CO <sub>2</sub>			H <sub>2</sub>	СО	CO <sub>2</sub>	
150 °C 180 °C 250 °C	0.002 0.0013 0.004	0.04 0.025 0.085	0.075 0.012 0.02	0.004 0.13 0.12		0.004 0.014 0.02	0.2 0.2 0.2	0.13 0.13 0.13	3.5 3.5 —
columnar Best for pumping						dense A first candidate for a barrier			
-	messenami i i	sunau	ata Ju	Muran					
er ganner		S. S	unanstva	44					
200 nm EHT	= 2.00 kV/ Sim	nal A - SE2	14 10 11 5041 65	200	) pm	EUT - 21	00 KV	Cincel A = CE	

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WD = 42 mm



### **NEG Coating/Double Layer Coating**



#### Daresbury/UK



There are two solutions to benefit from the low desorption yields and the high pumping speed and capacity: (1)vacuum firing of the vacuum chamber before NEG deposition, (2) a protective layer between the vacuum chamber material and a columnar NEG (for example, TiN or dense NEG coating).

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### **NEG Coating Benefit for Other Components**



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## **NEG Coating Cons(impedance issue)**

• At SOLEIL, the effect of NEG coating was also confirmed to contribute non-negligibly in the incoherent tune shifts arising from VC cross section asymmetry:



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### **NEG Coating Cons(impedance issue)**

- Resistive wall impedance of the NEG coating
  - An example of calculation in a case of NEG coated Cu sheet for the in-vacuum <u>undulator</u>.
  - Electric conductivity of NEG coating : 10<sup>6</sup>  $\Omega^{-1} m^{-1}$
  - cf. SUS :  $1.4X10^6 \Omega^{-1} m^{-1}$
  - Cylindrical approximation

• 
$$k_{loss} = \frac{6.38 \times 10^{12}}{g_u [\text{mm}] (\sigma_t^{\Box} [\text{ps}])^{1.5}}$$

• 
$$P_{RW} = \frac{\kappa_{loss}r_{l}}{f_{b}}$$

- For  $g_u = 4 \text{ mm}$ 
  - $1\,\mu m$  coating little affect the impedance.
- Cylindrical duct of Ø24 mm I. D.,
  - Power loss will be 1/6 of 4 mm duct, 200 W.
  - 23 W/m heat load is predicted for SUS pipe without Cu plating.
  - Heat load for the Cu pipe will be 4 W/m.
  - Suitable candidate of the duct material is OFHC Cu or Cu alloy.
  - Aluminum-alloy tube is considered a candidate where a deformed cross section is required.
  - SUS duct needs thick Cu plating.



KEK\_LS



### Some Specific Hardware Development

- Impedance: More gentle transition, no gap between flanges, RF shielded bellows... round chambers improve geometric impedance, smaller cross section...
- SOLEIL in-vacuum ID tapers





In-vacuum taper structure: Initial (above). Improved (below)

- Initial tapers creating a cavity structure when the ID gap was opened had a serious problem of beaminduced heating.
- New tapers greatly improved the heating issues.



### Some Specific Hardware Development



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### **Some Specific Hardware Development**



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### **Some Specific Hardware Development**



Simulations of narrow finger bellows: Inside fingers :  $K_{loss} \approx 1.9 \times 10^{-2} \text{ V/pC}$ Outside fingers :  $K_{loss} \approx 2.1 \times 10^{-2} \text{ V/pC}$ 

± 2 mm offset ≈ 21.4 x10<sup>-2</sup> V/pC ± 2 mm offset ≈ 8.7 x10<sup>-2</sup> V/pC

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### **Some Specific Hardware Development**



# The comb-type RF shield has a structure of nested comb teeth, and has higher thermal strength and lower impedance than the conventional finger-type one.

Advantages of the comb-type RF-shield are as follows:

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(1)The RF shield, i.e. the copper teeth, has a high thermal strength compared to thin fingers.

(2)There is no transverse step at inside surface in principle, and the shield has low impedance.

(3)The TE-mode like HOM, which can easily couple with the finger-type RF shield, hardly goes through due to the large radial thickness of teeth.

(4)There is no sliding point on the inner surface of beam duct, which otherwise could be a source of arcing.

(5) The RF shield can fit for beam ducts with various cross sections.

The potential disadvantages compared to the finger-type RF shield, on the other hand, are the limited stroke of expansion/contraction, typically  $\pm 4$  mm, and the small bending angle,  $\pm 30$  mrad at most.



### **Some Specific Hardware Development**



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### In-situ bake out/NEG coating activation

- Minimum gap needed between chamber and magnet poles(0.5~1.0mm)
- Chamber heating methods, how to apply thin radiation resistant heat films



- Different configurations of heating element arrangement have been developed
- Thermal simulation is being carried out by means of FE module of Solid Works





316L Sheathed heaters



Test shaping insulation coats (aluminum coated PI)

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### In-situ bake out/NEG coating activation



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### In-situ bake out/NEG coating activation



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# **Summary**

- The vacuum system for the next-generation ring-based LSs has to cope with high synchrotron radiation, high photon flux, intense HOM excitation, strong collective effect, and so on.
- The low emittance lattice is making the vacuum chambers and components more and more miniature, both transversely and longitudinally, making their designs and vacuum pumping difficult with classical pumps.
- Vacuum pumping with NEG coating on the other hand is becoming increasingly attractive for the future machines. The use of NEG coated chambers must be considered right on the beginning of the design phase since it has a huge impact on infrastructure, fabrication strategy, cleaning procedures, baking strategy, etc.
   We have experienced various problems during the operation 3<sup>rd</sup> generation LSs, and learned lots of things. These experiences should be some of help for the future design of next-generation LSs.

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# Thank you for your attention

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